

Title (en)

SULFATE BASED, AMMONIUM FREE TRIVALENT CHROMIUM DECORATIVE PLATING PROCESS

Title (de)

VERFAHREN ZUR DEKORATIVEN PLATTIERUNG MIT SULFATBASIERTEM, AMMONIUMFREIEM TRIVALENTEM CHROM

Title (fr)

PROCÉDÉ DE PLACAGE DÉCORATIF AU CHROME TRIVALENT SANS AMMONIUM À BASE DE SULFATE

Publication

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Application

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Abstract (en)

[origin: WO2021084103A1] The present invention refers to an electroplating bath for electroplating a chromium or chromium alloy layer, the bath comprising trivalent chromium ions, organic carboxylic acid, sulfate ions, sodium conductive ions, and additives in the form of inorganic sulfur compound and boric acid as well as a process using such an electroplating bath.

IPC 8 full level

C25D 3/06 (2006.01)

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